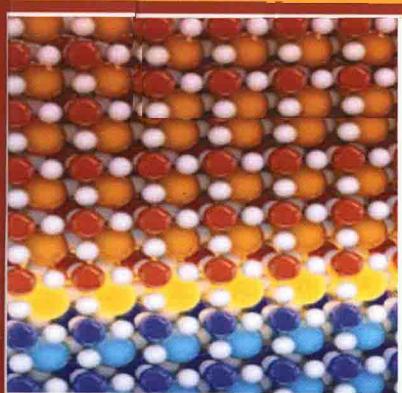


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Epitaxial Growth of Complex Metal Oxides

Edited by G. Koster, M. Huijben and G. Rijnders

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